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## RANSMITTAL OF FORMAL DRAWINGS

Docket No. YOR920030336US1 (16898)

In Re Application Of:

Timothy J. Dalton, et al.

Application No.	Filing Date	Confirmation No.	Examiner	Customer No.	Group Art Unit
10/685,012	10/14/03	4288	Edgardo Ortiz	23389	2815

Invention:

PHOTORESIST ASH PROCESS WITH REDUCED INTER-LEVEL DIELECTRIC (ILD) DAMAGE

Address to:

**Commissioner for Patents** P.O. Box 1450 Alexandria, VA 22313-1450

Transmitted herewith are:

2 sheets of formal drawing(s) for this application.

 $\boxtimes$ Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c).

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Leslie S. Szivos, Ph.D.

Registration No. 39,394

Dated: November 5, 2004

I certify that this document and attached formal drawings are being deposited on 11/05/04 U.S. Postal Service as first class mail under 37 C.F.R. 1.8 and addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Signature of Person Mailing Correspondence

Leslie S. Szivos, Ph.D.

Typed or Printed Name of Person Mailing Correspondence